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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/654,306	09/02/2003	Hiroyuki Tamura	44471-292097	4421
23370 7590 07/10/2007 JOHN S. PRATT, ESQ KILPATRICK STOCKTON, LLP		*	EXAMINER	
			REAMES, MATTHEW L	
1100 PEACHTREE STREET ATLANTA, GA 30309			ART UNIT	PAPER NUMBER
		. ·	. 2891	
·			MAIL DATE	DELIVERY MODE
		•	07/10/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	•	Application No.	Applicant(s)				
Office Action Summary		10/654,306	TAMURA ET AL.				
		Examiner	Art Unit				
	·	Matthew L. Reames	2891				
Period fo	- The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	orrespondence address				
VVHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DATES IN SIX (6) MONTHS from the mailing date of this communication. Operiod for reply is specified above, the maximum statutory period we are to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 6(a). In no event, however, may a reply be tim ill apply and will expire SIX (6) MONTHS from to cause the application to become ABANDONE	the mailing date of this communication.				
Status							
1)⊠	Responsive to communication(s) filed on 19 Ap	oril 2007	:				
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	·	. pane quayie, 1999 O.D. 11, 49	5 O.G. 215.				
Dispositi	on of Claims		·				
4)	4) ☐ Claim(s) 1,4-8,12 and 13 is/are pending in the application.						
	4a) Of the above claim(s) 10,11 and 14 is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)□	6) Claim(s) <u>1,4-8,12 and 13</u> is/are rejected.						
7)	Claim(s) is/are objected to.	·	•				
8)	Claim(s) are subject to restriction and/or	election requirement.					
Applicati	on Papers						
9) 🔲 -	The specification is objected to by the Examiner		•				
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
	nder 35 U.S.C. § 119						
		• " • • • • • • • • • • • • • • • • • •					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a) All b) Some * c) None of:							
1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No.							
 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage 							
			in this National Stage				
* \$	application from the International Bureau		•				
J	ee the attached detailed Office action for a list of	i the certified copies not received	l .				
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Attachment	· ·	•					
	Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date Information Disclosure Statement(s) (PTO/SB/08) 5) Notice of Informal Patent Application							
	No(s)/Mail Date	6) Other:					
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DETAILED ACTION

Response to Arguments

In regards to Applicants suggestion that Tamura's teaches a "high precision lattice structures" (i.e. no fluctuations in the lattice structure), Tamura recites no such statement. Further, Tamura's system is a quantum mechanical system, these systems are well known for the fluctuations occur for example Tamura explicitly mentions on page 085324-6 that fluctuations occur I the spin spin correlation function due to thermal excitations. Further Applicant invention is directed toward a lattice structure (see first paragraph of applicant's summary of invention). Since Applicant's structure is a lattice as well does it mean it cannot fluctuate either?

The claim requires that it be permitted to fluctuate in the region. Tamura teaches the device can modify the size of the dots (see page 085324-5), which is a fluctuation in size. Further, it is clear that Tamura system will fluctuate due to thermal excitations. In either case the device of Tamura is capable of allowing fluctuations of the magnitude claimed depending on the confinement energy. Therefore the fluctuation is being interpreted as an intended use of the device. The Examiner notes that a recitation of the intended use of the claimed invention must result in a structural difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim. See, e.g., *In re Pearson*, 18 1 USPQ 641 (CCPA); *In re Minks*, 169 USPQ 120 (Bd Appeals); In re Casey, 152 USPQ 235 (CCPA 1967); *In re Otto*, 136 USPQ 458, 459 (CCPA 1963); See MPEP §2114. The recitation of

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"permitting a fluctuation", does not distinguish the present invention over Tamura who teaches the structure as claimed.

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claim 1-8,12 are rejected under 35 U.S.C. 102(b) as being Tamura by Phys. Rev. B Feb 2002).
 - a. As to claim 1,4-8, Tamura teaches a magnetic body composed of non-magnetic material (see abstract) comprising a plurality of localize electron regions in each of which at least one electron is confined to form a localized spin (see section IV); a barrier potential region having a higher energy than the Fermi energy of the electron in the localized region and confining the electron within the respective localized electron regions (see section IV); a conductive electron region including a conductive electron system having a lower energy than an energy of the barrier potential region (see section V); wherein the localized respective localized electron regions are disposed separate from one another via the barrier potential region and conductive region to show ferromagnetism based on an interaction between localized spins through the conductive electron region (see abstract and section IV). Tamura further teaches quantum dot (see abstract). Tamura further teaches a GaAs InAs and Si quantum dot of 5 nm

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further through biasing the gate the Fermi wavelength can be modified as desired. Regarding claim 3-8, the manner of operating the device does not differentiate an apparatus claim from the prior art. A claim containing a "recitation with respect to the manner in which a claimed apparatus is intended to be employed does not differentiate the claimed apparatus from a prior art apparatus" if the prior art apparatus teaches all the structural limitations of the claim. *Ex parte Masham*, 2 USPQ2d 1647 (Bd. Pat. App. & Inter. 1987) See MPEP §2114. The recitation of "Fermi wavelength" and "permitting a fluctuation" is an intended use language which does not differentiate the claimed device from the prior art device of Tamura, who teaches the structure of the claim as described above.

e. As to claim 12, Tamura a semiconductor quantum dot.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claim 9 and 13 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tamura.
 - a. As to claim 9, Tamura does not explicitly teach the width of the barrier layer as claimed.

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However it would have been obvious to one of ordinary skill in the art a t the time of the invention to have optimized the the barrier with to less than half of a length subtracting the size of the quantum dot along ethe direction in which electrons are confined.

One would have been so motivated to optimize tunneling from the conductive region into the dots.

"[W]here the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation." In re Aller, 220 F.2d 454, 456, 105 USPQ 233, 235 (CCPA) 1955) (Claimed process which was performed at a temperature between 40°C and 80°C and an acid concentration between 25% and 70% was held to be prima facie obvious over a reference process which differed from the claims only in that the reference process was performed at a temperature of 100°C and an acid concentration of 10%.); see also Peterson, 315 F.3d at 1330, 65 USPQ2d at 1382 ("The normal desire of scientists or artisans to improve upon what is already generally known provides the motivation to determine where in a disclosed set of percentage ranges is the optimum combination of percentages."); In re Hoeschele, 406 F.2d 1403, 160 USPQ 809 (CCPA 1969) (Claimed elastomeric polyurethanes which fell within the broad scope of the references were held to be unpatentable thereover because, among other reasons, there was no evidence of the criticality of the claimed ranges of molecular weight or molar proportions.). For more recent cases applying this

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principle, see Merck & Co. Inc. v. Biocraft Laboratories Inc., 874 F.2d 804, 10 USPQ2d 1843 (Fed. Cir.), cert. denied, 493 U.S. 975 (1989); In re Kulling, 897 F.2d 1147, 14 USPQ2d 1056 (Fed. Cir. 1990); and In re Geisler, 116 F.3d 1465, 43 USPQ2d 1362 (Fed. Cir. 1997).

b. As to claim 13, Tamura teaches all the elements of claim 1 and all the elements of claim 13 except Tamura does not teach a an insulation layer.

However it would have been obvious to one of ordinary skill in the art at the time of the invention to separate the gate from the region, as required by Tamura (pg 085324-1 column 2) by using a insulation layer such as silicon oxide.

One would have been so motivated since insulator as silicon oxide where conventional in the semiconductor art and would have therefore provided a cost benefit.

The Examiner notes that a recitation of the intended use of the claimed invention must result in a structural difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim. See, e.g., *In re Pearson*, 18 1 USPQ 641 (CCPA); *In re Minks*, 169 USPQ 120 (Bd Appeals); In re Casey, 152 USPQ 235 (CCPA 1967); *In re Otto*, 136 USPQ 458, 459 (CCPA 1963); See MPEP §2114. The recitation of "permitting a fluctuation", does not distinguish the present invention over Tamura who teaches the structure as claimed.

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Conclusion

5. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew L. Reames whose telephone number is (571)272-2408. The examiner can normally be reached on M-Th 6:30-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, B. William Baumeister can be reached on (571)272-1722. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

MLR

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